

PATENT

I hereby certify that on the date specified below, this correspondence is being deposited with the United States Postal Service as first-class mail in an envelope addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.

31, 2007

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Scott E. Moore

Attorney Docket No.: 500170.05

Serial No. : 09/782,892

Patent No. : US 6,969,297 B2 Issue Date: November 29, 2005

Filed

: February 13, 2001

: APPARATUS AND METHOD FOR CONDITIONING AND MONITORING MEDIA Title USED FOR CHEMICAL-MECHANICAL PLANARIZATION

REQUEST FOR CERTIFICATE OF CORRECTION

Certificate

SEP 0 6 2007

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

of Correction

Sir:

A Certificate of Correction under 35 U.S.C. § 254 is respectfully requested for the above-identified patent in order to correct Patent and Trademark Office errors made during the printing of the patent or in the original application. The changes in the patent needed to correct the errors are as follows:

Column, Line	Reads	Should Read
Column 3, Line 5	"Alternatively, (for example,"	Alternatively (for example,
Column 3, Line 29	"signal received form"	signal received from
Column 5, Line 27	"material removed form"	material removed from
Column 6, Line 46	"the two surface."	the two surfaces
Column 6, Lines 47-50	"The relative velocity between the two surfaces can	The relative velocity between the two surfaces can in turn be a

in turn be a function of the rotational and/or translational

speed of the polishing pad 127, the position of the conditioning body 150 relative to the polishing pad 127."

Column 7, Line 35 "force sensor 180 can be"

"then toward" Column 8, Line 8

Column 24, Lines 33-40

"a conditioning body adjacent to the planarizing medium, at least one of the conditioning body and the planarizing medium being movable relative to the other of the conditioning body and the planarizing medium for conditioning the planarizing surface, the conditioning body and the planarizing medium generating a force in the planarizing medium moves relative to the other of the conditioning body and the planarizing medium;"

Column 24, Line 52 "detect the force; the sensor"

Column 27, Line 57 "the sensor is positioned" function of the rotational and/or translational speed of the polishing pad 127, the rotational and/or translational speed of the conditioning body 150, and the position of the conditioning body 150 relative to the polishing pad 127."

--force sensor 180, can be--

--than toward--

--a conditioning body adjacent to the planarizing medium, at least one of the conditioning body and the planarizing medium being movable relative to the other of the conditioning body and the planarizing medium for conditioning the planarizing surface, the conditioning body and the planarizing medium generating a force in the planarizing surface plane when the one of the conditioning body and the planarizing medium moves relative to the other of the conditioning body and the planarizing medium;"

--detect the force, the sensor--

-- the sensor positioned--

The above errors for which correction is requested under 35 U.S.C. § 254 were made in the printing of the patent or in the original application. The errors are considered sufficiently important to justify the processing of a Certificate of Correction under 35 U.S.C. § 254. A Form PTO-1050, in duplicate, is enclosed herewith.

The Commissioner is hereby authorized to charge payment of any fees associated with this communication to Deposit Account No. 50-1266. A duplicate copy of this sheet is enclosed.

Favorable consideration of this Request is respectfully requested.

Respectfully submitted,

Date: (1119. 29 2007

 $\mathbf{R}\mathbf{v}$

Edward W. Bulchis, Reg. No. 26,847

Customer No. 27,076
Dorsey & Whitney LLP
1420 Fifth Avenue, Suite 3400

Seattle, WA 98101 (206) 903-8785

Attorney for Applicant(s)

EWB:tdp

Enclosures:

Postcard

Form PTO-1050 (+ copy)

UNITED STATES PATENT AND TRADEMARK OFFICE CERTIFICATE OF CORRECTION

PATENT NO.

US 6,969,297 B2

DATED

November 29, 2005

INVENTOR(S)

Scott E. Moore

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Column 7, Line 35	"force sensor 180 can be"	force sensor 180, can be 6 2007
Column 8, Line 8	"then toward"	than toward
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	conditioning body and the	conditioning body and the
	planarizing medium for	planarizing medium for
	conditioning the	conditioning the
	planarizing surface, the	planarizing surface, the
	conditioning body and the	conditioning body and the
	planarizing medium	planarizing medium
	generating a force in the	generating a force in the
	planarizing medium	planarizing surface plane
	moves relative to the	when the one of the
	other of the conditioning	conditioning body and the
	body and the planarizing	planarizing medium
	medium;"	moves relative to the
		other of the conditioning
	•	body and the planarizing
		medium;"
Column 24, Line 52	"detect the force; the	detect the force, the
	sensor"	sensor
Column 27, Line 57	"the sensor is positioned"	the sensor positioned

MAILING ADDRESS OF SENDER:

Patent No. <u>US 6,969,297 B2</u>

DORSEY & WHITNEY LLP 1420 Fifth Avenue, Suite 3400 Seattle, Washington 98101 No. add'l. copies @ .30 per page

FORM PTO-1050 (REV. 3-82)

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Scott E. Moore Attorney Docket No.: 500170.05

Patent No. : US 6,969,297 B2 Serial No. : 09/782,892

Issue Date: November 29, 2005 Filed: February 13, 2001

Title : APPARATUS AND METHOD FOR CONDITIONING AND MONITORING MEDIA

USED FOR CHEMICAL-MECHANICAL PLANARIZATION

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Column 7, Line 35

"force sensor 180 can be"

--force sensor 180, can be--

Column 8, Line 8

"then toward"

--than toward--

Column 24, Lines 33-40

"a conditioning body adjacent to the planarizing medium, at least one of the conditioning body and the planarizing medium being movable relative to the other of the conditioning body and the planarizing medium for conditioning the planarizing surface, the conditioning body and the planarizing medium generating a force in the planarizing medium moves relative to the other of the conditioning body and the planarizing medium;"

--a conditioning body adjacent to the planarizing medium, at least one of the conditioning body and the planarizing medium being movable relative to the other of the conditioning body and the planarizing medium for conditioning the planarizing surface, the conditioning body and the planarizing medium generating a force in the planarizing surface plane when the one of the conditioning body and the planarizing medium moves relative to the other of the conditioning body and the planarizing medium;"

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"detect the force; the sensor"

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"the sensor is positioned"

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Enclosures:

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UNITED STATES PATENT AND TRADEMARK OFFICE **CERTIFICATE OF CORRECTION**

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November 29, 2005

DATED : INVENTOR(S) :

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